Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	392	((porous rough$4 pore porosity) same (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source)) and "313"/$. ccls. and cathode and anode	US-PGPUB; USPAT	OR	ON	2005/05/17 16:05
L2	242	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source)) and "313"/$.ccls. and cathode and anode	US-PGPUB; USPAT	OR	ON	2005/05/17 16:05
L3	287	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source)) and "313"/$.ccls. and (etch$3 remov$3)	US-PGPUB; USPAT	OR	ON	2005/05/17 17:04
L4	57	("3735186" | "3755704" | "4652467" | "4940916" | "4987101" | "5103288" | "5194780" | "5225820" | "5393712").PN. OR ("5525857"). URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:15
L5	56	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source)) and (etch$3 remov$3)	EPO; JPO; DERWENT	OR	ON	2005/05/17 16:21
L6	302	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source))	EPO; JPO; DERWENT	OR	ON	2005/05/17 16:22
L7	180	((porous rough$4 pore porosity) near3 (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source))	EPO; JPO; DERWENT	OR	ON	2005/05/17 16:38
L8	1	"6835111".pn.	EPO; JPO; DERWENT	OR	ON	2005/05/17 16:40
L9	1	"6835111".pn.	US-PGPUB; USPAT	OR	ON	2005/05/17 16:40

L10	42	("3665241" | "3755704" | "3812559" | "3954523" | "4016017" | "4266233" | "4652467" | "4857161" | "4987101" | "5103288" | "5142184" | "5186670" | "5194780" | "5229331" | "5259799" | "5358908" | "5372973" | "5430300" | "5458518" | "5470801" | "5473222" | "5483067" | "5529524" | "5569058" | "5578896" | "5585301" | "5597444" | "5653619" | "5663608" | "5684356" | "5712534" | "5793154" | "5804910" | "5853492" | "5869169" | "5898258" | "6028322" | "6232705" | "6251470" | "6255156" | "6277765" | "6333215").PN. OR ("6835111").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:40
L11	12	("3998678" | "4410832" | "4663559" | "4835438" | "4990766" | "5012153" | "5136205" | "5189341" | "5256936").PN. OR ("5793154"). URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:42
L12	146	("3475664" | "3506506" | "3531857" | "3665241" | "3700510" | "3755704").PN. OR ("3998678").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:50
L13	67	("3755704" | "3789471" | "3812559" | "3894332" | "3921022" | "3998678" | "4008412" | "4178531" | "4307507" | "4513308" | "4536942" | "4578614" | "4685996" | "4721885" | "4827177" | "4874981" | "4970887" | "4975382").PN. OR ("5007873").URPN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:48
L14	15	(("3755704" | "3789471" | "3812559" | "3894332" | "3921022" | "3998678" | "4008412" | "4178531" | "4307507" | "4513308" | "4536942" | "4578614" | "4685996" | "4721885" | "4827177" | "4874981" | "4970887" | "4975382").PN. OR ("5007873").URPN.) and (pore porosity porous rough$4)	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:48

L15	27	(("3475664" | "3506506" | "3531857" | "3665241" | "3700510" | "3755704").PN. OR ("3998678").URPN.) and (pore porosity porous rough$4)	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/17 16:51
L16	987	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source)) and "438"/$.ccls. and (etch$3 remov$3)	US-PGPUB; USPAT	OR	ON	2005/05/17 17:04
L17	110	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron field) with (emission emitting emissive source)) and "445"/$.ccls. and (etch$3 remov$3)	US-PGPUB; USPAT	OR	ON	2005/05/17 17:05
L18	1081	16 17	US-PGPUB; USPAT	OR	ON	2005/05/17 17:04
L19	485	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and ((electron) with (emission emitting emissive source)) and "438"/$.ccls. and (etch$3 remov$3)	US-PGPUB; USPAT	OR	ON	2005/05/17 17:04
L20	579	19 17	US-PGPUB; USPAT	OR	ON	2005/05/17 17:05
L21	244	((porous rough$4 pore porosity) with (SiO silicon insulat$3 isolat$3 dielectic)) and (electron near3 (emission emitting emissive source)) and ("438"/$.ccls. "445"/$.ccls.) and ((etch$3 remov$3) same (SiO silicon insulat$3 isolat$3 dielectic))	US-PGPUB; USPAT	OR	ON	2005/05/17 17:07